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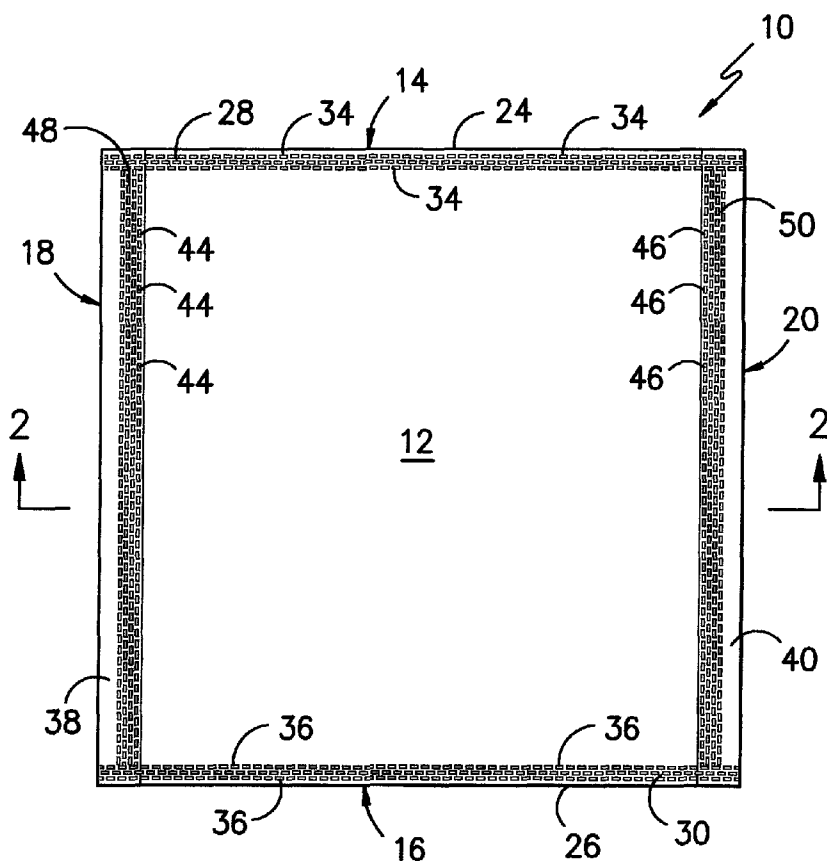
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**(54) Title:** LOW CONTAMINANT WIPER



**(57) Abstract:** A low particle generating wiper for use in a particle sensitive environment. The wiper is constructed at least partly of a textile fabric formed from a multiplicity of yarns including thermoplastic filaments. The wiper includes an interior surrounded by perimeter edges. The perimeter edges are constructed such that filaments within the yarns at the perimeter edge undergo a reduced occurrence of fracture under tension thereby potentially reducing particle generation during use.



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